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Please find below and/or attached an Office communication concerning this application or proceeding.

	Applicati n N .	Applicant(s)	
	09/671,654	YAMAZAKI ET AL.	
Office Action Summary	Examin r	Art Unit	
	Glenn Zimmerman	2879	
The MAILING DATE f this communication app Period f r Reply	pears n the cover she t with the c	orresp ndenc address	
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, the maximum statutory period v - Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be timy within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).	
Status			
1) Responsive to communication(s) filed on	<u>_</u> .		
2a) ☐ This action is FINAL . 2b) ☑ This	action is non-final.		
3) Since this application is in condition for alloward closed in accordance with the practice under E			
Disposition of Claims			
 4) Claim(s) 1-12 is/are pending in the application. 4a) Of the above claim(s) is/are withdraw 5) Claim(s) is/are allowed. 6) Claim(s) 1-12 is/are rejected. 7) Claim(s) is/are objected to. 	wn from consideration.		
8) ☐ Claim(s) are subject to restriction and/o Application Papers	r election requirement.	•	
9)☐ The specification is objected to by the Examine			
10) ☐ The drawing(s) filed on 29 December 2003 is/a Applicant may not request that any objection to the	• • • • • • • • • • • • • • • • • • • •	•	
Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Ex		• •	
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the priority documents application from the International Bureau * See the attached detailed Office action for a list	s have been received. s have been received in Application rity documents have been receive u (PCT Rule 17.2(a)).	on No ed in this National Stage	
•			
Attachment(s)	. 🗖		
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date <u>0404, 0304</u>. 	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal Pa		

Art Unit: 2879

DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1, 3, 7 and 9 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shi et al. U.S. Patent 5,998,805 in view of Eida et al. U.S. Patent 5,909,081, Shibata et al. U.S. Patent 6,147,451 and Rogers U.S. Patent 6,081,071.

Regarding claim 1, Shi et al. teaches an active matrix type organic EL display (title) device comprising: an insulating gate field effect transistor (ref. 30 gate oxide; transistor ref. 26 which is part of an OED ref. 39) provided on a semiconductor substrate (semiconductor substrate ref. 25) an EL layer comprising an organic material (organic layers ref. 41-43a) provided over the insulated gate field effect transistor a cover plate (separate glass substrate ref. 49) formed of an insulating material, a packing material for bonding (col. 8 line 10), but fails to teach a single crystal semiconductor substrate, a bed plate, wherein the single crystal semiconductor substrate is held in a vacant space which is defined by the bed plate and the cover plate and the packing material wherein the vacant space is filled with an inert gas and a drying agent. Eida et al. in the analogous art teaches a bed plate (ceramic plate support substrate Fig. 1 ref. 2) and cover plate (transparent inorganic oxide



substrate ref. 4) and packing material (sealing means, bonding ref. 5) wherein an organic EL device is held (ref. 1 OED or OLED) wherein the vacant space is filled with an inert gas (col. 21 lines 60-62). Additionally, Eida teaches incorporation of such a bed plate (ceramic plate support substrate Fig. 1 ref. 2) and cover plate (transparent inorganic oxide substrate ref. 4) and packing material (sealing means, bonding ref. 5) wherein an organic EL device is held (ref. 1 OED or OLED) wherein the vacant space is filled with an inert gas (col. 21 lines 60-62) to improve light emission life and angle-of-view characteristics (abstract; col. 21 lines 64-67) and prevent oxidation (col. 21 line 63). Shibata et al. in the analogous art teaches a transistor (transistor ref. 1Tr1) provided on a single crystal semiconductor substrate (ref. 1 monocrystalline silicon semiconductor substrate). Additionally, Shibata teaches incorporation of such teaches a transistor (transistor ref. 1Tr1) provided on a single crystal semiconductor substrate to improve providing ease of incorporation of a driving integrated circuit and prevent the need for providing external driving integrated circuits (col. 2 lines 11-17). Rogers in the analogous art teaches a vacant spaced filled with a drying agent (desiccant ref. 31). Additionally, Rogers teaches incorporation of such a drying agent to improve drying and provide an improved organic EL apparatus that is highly resistant to water, oxygen and other environmental elements (col. 1 lines 66-67 and col. 2 lines 1 and 2).

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use a bed and cover plate and packing material wherein an organic EL device is held wherein the vacant space is filled with an

Art Unit: 2879

inert gas in the active matrix oed array of Shi et al., since such a modification would improve light emission life and angle-of-view characteristics and prevent oxidation as taught by Eida.

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to have a transistor provided on a single crystal semiconductor substrate in the semiconductor substrate of Shi et al., since such a modification would improve providing ease of incorporation of a driving integrated circuit and prevent the need for providing external driving integrated circuits as taught by Shibata.

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use a drying agent in the space/gap in the active matrix oed of Shi, since such a modification would improve drying and provide an improved organic EL apparatus that is highly resistant to water, oxygen and other environmental elements as taught by Rogers.

Regarding claim 3, Shi et al. teaches an active matrix type organic EL display (title) device comprising: an insulating gate field effect transistor (ref. 30 gate oxide; transistor ref. 26 which is part of an OED ref. 39) provided on a semiconductor substrate (semiconductor substrate ref. 25) an EL layer comprising an organic material (organic layers ref. 41-43a) provided over the insulated gate field effect transistor a cover plate (separate glass substrate ref. 49) formed of an insulating material, a packing material for bonding (col. 8 line 10) wherein the cover plate comprises a transparent material in a region of the cover plate overlapping with the pixel

Art Unit: 2879

section (separat glass substrate r f. 49), but fails to teach a single crystal semiconductor substrate, a bed plate, wherein the single crystal semiconductor substrate is held in a vacant space which is defined by the bed plate and the cover plate and the packing material wherein the vacant space is filled with an inert gas and a drying agent. Eida et al. in the analogous art teaches a bed plate (ceramic plate support substrate Fig. 1 ref. 2) and cover plate (transparent inorganic oxide substrate ref. 4) and packing material (sealing means, bonding ref. 5) wherein an organic EL device is held (ref. 1 OED or OLED) wherein the vacant space is filled with an inert gas (col. 21 lines 60-62). Additionally, Eida teaches incorporation of such a bed plate (ceramic plate support substrate Fig. 1 ref. 2) and cover plate (transparent inorganic oxide substrate ref. 4) and packing material (sealing means, bonding ref. 5) wherein an organic EL device is held (ref. 1 OED or OLED) wherein the vacant space is filled with an inert gas (col. 21 lines 60-62) to improve light emission life and angle-of-view characteristics (abstract; col. 21 lines 64-67) and prevent oxidation (col. 21 line 63). Shibata et al. in the analogous art teaches a transistor (transistor ref. 1Tr1) provided on a single crystal semiconductor substrate (ref. 1 monocrystalline silicon semiconductor substrate). Additionally, Shibata teaches incorporation of such teaches a transistor (transistor ref. 1Tr1) provided on a single crystal semiconductor substrate to improve providing ease of incorporation of a driving integrated circuit and prevent the need for providing external driving integrated circuits (col. 2 lines 11-17). Rogers in the analogous art teaches a vacant spaced filled with a drying agent (desiccant ref. 31). Additionally, Rogers teaches incorporation of

Art Unit: 2879

such a drying agent to improve drying and provide an improved organic EL apparatus that is highly resistant to water, oxygen and other environmental elements (col. 1 lines 66-67 and col. 2 lines 1 and 2).

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use a bed and cover plate and packing material wherein an organic EL device is held wherein the vacant space is filled with an inert gas in the active matrix oed array of Shi et al., since such a modification would improve light emission life and angle-of-view characteristics and prevent oxidation as taught by Eida.

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to have a transistor provided on a single crystal semiconductor substrate in the semiconductor substrate of Shi et al., since such a modification would improve providing ease of incorporation of a driving integrated circuit and prevent the need for providing external driving integrated circuits as taught by Shibata.

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use a drying agent in the space/gap in the active matrix oed of Shi, since such a modification would improve drying and provide an improved organic EL apparatus that is highly resistant to water, oxygen and other environmental elements as taught by Rogers.

Regarding claim 7, Shi et al. teaches an active matrix type organic EL display (title) device comprising: an insulating gate field effect transistor (ref. 30 gate oxide;

Art Unit: 2879

transistor r f. 26 which is part of an OED ref. 39) provided on a semiconductor substrate (semiconductor substrate ref. 25) an EL layer comprising an organic material (organic layers ref. 41-43a) provided over the insulated gate field effect transistor a cover plate (separate glass substrate ref. 49) formed of an insulating material, a binder layer (col. 8 line 10), but fails to teach a single crystal semiconductor substrate, a bed plate, wherein the single crystal semiconductor substrate is held in a vacant space which is defined by the bed plate and the cover plate and the packing material wherein the vacant space is filled with an inert gas and a drying agent. Eida et al. in the analogous art teaches a bed plate (ceramic plate support substrate Fig. 1 ref. 2) and cover plate (transparent inorganic oxide substrate ref. 4) and binder layer (sealing means, bonding ref. 5; this clearly is a layer as is lays around the circumference of the display) wherein an organic EL device is held (ref. 1 OED or **OLED)** wherein the vacant space is filled with an inert gas (col. 21 lines 60-62). Additionally, Eida teaches incorporation of such a bed plate (ceramic plate support substrate Fig. 1 ref. 2) and cover plate (transparent inorganic oxide substrate ref. 4) and a binder layer (sealing means, bonding ref. 5) wherein an organic EL device is held (ref. 1 OED or OLED) wherein the vacant space is filled with an inert gas (col. 21 lines 60-62) to improve light emission life and angle-of-view characteristics (abstract; col. 21 lines 64-67) and prevent oxidation (col. 21 line 63). Shibata et al. in the analogous art teaches a transistor (transistor ref. 1Tr1) provided on a single crystal semiconductor substrate (ref. 1 monocrystalline silicon semiconductor substrate). Additionally, Shibata teaches incorporation of such teaches a transistor (transistor ref.

1Tr1) provided on a single crystal semiconductor substrate to improve providing ease of incorporation of a driving integrated circuit and prevent the need for providing external driving integrated circuits (col. 2 lines 11-17). Rogers in the analogous art teaches a vacant spaced filled with a drying agent (desiccant ref. 31). Additionally, Rogers teaches incorporation of such a drying agent to improve drying and provide an improved organic EL apparatus that is highly resistant to water, oxygen and other environmental elements (col. 1 lines 66-67 and col. 2 lines 1 and 2).

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use a bed and cover plate and packing material wherein an organic EL device is held wherein the vacant space is filled with an inert gas in the active matrix oed array of Shi et al., since such a modification would improve light emission life and angle-of-view characteristics and prevent oxidation as taught by Eida.

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to have a transistor provided on a single crystal semiconductor substrate in the semiconductor substrate of Shi et al., since such a modification would improve providing ease of incorporation of a driving integrated circuit and prevent the need for providing external driving integrated circuits as taught by Shibata.

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use a drying agent in the space/gap in the active matrix oed of Shi, since such a modification would improve drying and provide an

Art Unit: 2879

improved organic EL apparatus that is highly resistant to water, oxygen and other environmental elements as taught by Rogers.

Regarding claim 9, Shi et al. teaches an active matrix type organic EL display (title) device comprising: an insulating gate field effect transistor (ref. 30 gate oxide; transistor ref. 26 which is part of an OED ref. 39) provided on a semiconductor substrate (semiconductor substrate ref. 25) an EL layer comprising an organic material (organic layers ref. 41-43a) provided over the insulated gate field effect transistor a cover plate (separate glass substrate ref. 49) formed of an insulating material, a binder layer (col. 8 line 10; this clearly is a layer) wherein the cover plate comprises a transparent material in a region of the cover plate overlapping with the pixel section (separate glass substrate ref. 49), but fails to teach a single crystal semiconductor substrate, a bed plate, wherein the single crystal semiconductor substrate is held in a vacant space which is defined by the bed plate and the cover plate and the packing material wherein the vacant space is filled with an inert gas and a drying agent. Eida et al. in the analogous art teaches a bed plate (ceramic plate support substrate Fig. 1 ref. 2) and cover plate (transparent inorganic oxide substrate ref. 4) and binder layer (sealing means, bonding ref. 5; this clearly is a layer) wherein an organic EL device is held (ref. 1 OED or OLED) wherein the vacant space is filled with an inert gas (col. 21 lines 60-62). Additionally, Eida teaches incorporation of such a bed plate (ceramic plate support substrate Fig. 1 ref. 2) and cover plate (transparent inorganic oxide substrate ref. 4) and binder layer (sealing means, bonding ref. 5) wherein an organic EL device is held (ref. 1 OED or OLED)

wherein the vacant space is filled with an inert gas (col. 21 lin s 60-62) to improve light emission life and angle-of-view characteristics (abstract; col. 21 lines 64-67) and prevent oxidation (col. 21 line 63). Shibata et al. in the analogous art teaches a transistor (transistor ref. 1Tr1) provided on a single crystal semiconductor substrate (ref. 1 monocrystalline silicon semiconductor substrate). Additionally, Shibata teaches incorporation of such teaches a transistor (transistor ref. 1Tr1) provided on a single crystal semiconductor substrate to improve providing ease of incorporation of a driving integrated circuit and prevent the need for providing external driving integrated circuits (col. 2 lines 11-17). Rogers in the analogous art teaches a vacant spaced filled with a drying agent (desiccant ref. 31). Additionally, Rogers teaches incorporation of such a drying agent to improve drying and provide an improved organic EL apparatus that is highly resistant to water, oxygen and other environmental elements (col. 1 lines 66-67 and col. 2 lines 1 and 2).

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use a bed and cover plate and packing material wherein an organic EL device is held wherein the vacant space is filled with an inert gas in the active matrix oed array of Shi et al., since such a modification would improve light emission life and angle-of-view characteristics and prevent oxidation as taught by Eida.

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to have a transistor provided on a single crystal semiconductor substrate in the semiconductor substrate of Shi et al., since such a

Art Unit: 2879

modification would improve providing ease of incorporation of a driving integrated circuit and prevent the need for providing external driving integrated circuits as taught by Shibata.

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use a drying agent in the space/gap in the active matrix oed of Shi, since such a modification would improve drying and provide an improved organic EL apparatus that is highly resistant to water, oxygen and other environmental elements as taught by Rogers.

Claims 2, 4, 8 and 10 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shi et al. U.S. Patent 5,998,805 in view of Eida et al. U.S. Patent 5,909,081, Shibata et al. U.S. Patent 6,147,451, Rogers U.S. Patent 6,081,071 and Rallison et al. U.S. Patent 6,097,543.

Regarding claim 2, Shi, Eida, Shibata and Rogers teach all the limitations of claim 2, but fail to teach use of an EL display device in a goggle type display device.

Rallison in the analogous art teaches use of an EL display device in a goggle type display device (LED image generator for HMD ref. 2). Additionally, Rallison teaches incorporation of such a goggle type LED display to improve the combining of generated images with a view of the environment surround a user and transmit such combined visual information to the eye of the user (col. 1 lines 12-15).

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use a goggle type LED display in the active matrix OED of Shi, Eida, Shibata and Rogers, since such a modification would improve

improve the combining of generated images with a view of the environment surround a user and transmit such combined visual information to the eye of the user as taught by Rallison et al.

Regarding claim 4, Shi, Eida, Shibata and Rogers teach all the limitations of claim 4, but fail to teach use of an EL display device in a goggle type display device.

Rallison in the analogous art teaches use of an EL display device in a goggle type display device (LED image generator for HMD ref. 2). Additionally, Rallison teaches incorporation of such a goggle type LED display to improve the combining of generated images with a view of the environment surround a user and transmit such combined visual information to the eye of the user (col. 1 lines 12-15).

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use a goggle type LED display in the active matrix OED of Shi, Eida, Shibata and Rogers, since such a modification would improve improve the combining of generated images with a view of the environment surround a user and transmit such combined visual information to the eye of the user as taught by Rallison et al.

Regarding claim 8, Shi, Eida, Shibata and Rogers teach all the limitations of claim 8, but fail to teach use of an EL display device in a goggle type display device.

Rallison in the analogous art teaches use of an EL display device in a goggle type display device (LED image generator for HMD ref. 2). Additionally, Rallison teaches incorporation of such a goggle type LED display to improve the combining of generated

images with a view of the environment surround a user and transmit such combined visual information to the eye of the user (col. 1 lines 12-15).

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use a goggle type LED display in the active matrix OED of Shi, Eida, Shibata and Rogers, since such a modification would improve improve the combining of generated images with a view of the environment surround a user and transmit such combined visual information to the eye of the user as taught by Rallison et al.

Regarding claim 10, Shi, Eida, Shibata and Rogers teach all the limitations of claim 10, but fail to teach use of an EL display device in a goggle type display device. Rallison in the analogous art teaches use of an EL display device in a goggle type display device (LED image generator for HMD ref. 2). Additionally, Rallison teaches incorporation of such a goggle type LED display to improve the combining of generated images with a view of the environment surround a user and transmit such combined visual information to the eye of the user (col. 1 lines 12-15).

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use a goggle type LED display in the active matrix OED of Shi, Eida, Shibata and Rogers, since such a modification would improve improve the combining of generated images with a view of the environment surround a user and transmit such combined visual information to the eye of the user as taught by Rallison et al.

Art Unit: 2879

Claims 5 and 11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shi et al. U.S. Patent 5,998,805 in view of Eida et al. U.S. Patent 5,909,081, Shibata et al. U.S. Patent 6,147,451, Rogers U.S. Patent 6,081,071 and Kawami et al. U.S. Patent 5,882,761.

Regarding claim 5, Shi et al. teaches an active matrix type organic EL display (title) device comprising: an insulating gate field effect transistor (ref. 30 gate oxide; transistor ref. 26 which is part of an OED ref. 39) provided on a semiconductor substrate (semiconductor substrate ref. 25) an EL layer comprising an organic material (organic layers ref. 41-43a) provided over the insulated gate field effect transistor a cover plate (separate glass substrate ref. 49), a packing material for bonding (col. 8 line 10) and wherein the cover plate comprises a transparent material in a region of the cover plate overlapping with the pixel section (separate glass substrate ref. 49), but fails to teach a single crystal semiconductor substrate, a bed plate and cover plate formed of ceramics material, wherein the single crystal semiconductor substrate is held in a vacant space which is defined by the bed plate and the cover plate and the packing material wherein the vacant space is filled with an inert gas selected from the group consisting of helium, argon, krypton, xenon and nitrogen, and is filled with a drying agent selected from the group consisting of barium oxide and silica gel. Eida et al. in the analogous art teaches a bed plate (ceramic plate support substrate Fig. 1 ref. 2) and cover plate (transparent inorganic oxide substrate aluminum oxide ref. 4) and packing material (sealing means, bonding ref. 5) wherein an organic EL device is held (ref. 1 OED or OLED) wherein the vacant space is filled with an inert

gas selected from the group consisting of helium, argon, krypton, xenon and nitrogen, (col. 21 lines 60-62). Additionally, Eida teaches incorporation of such a bed plate (ceramic plate support substrate Fig. 1 ref. 2) and cover plate (transparent inorganic oxide substrate ref. 4) and packing material (sealing means, bonding ref. 5) wherein an organic EL device is held (ref. 1 OED or OLED) wherein the vacant space is filled with an inert gas (argon gas col. 21 lines 60-62) to improve light emission life and angle-of-view characteristics (abstract; col. 21 lines 64-67) and prevent oxidation (col. 21 line 63). Shibata et al. in the analogous art teaches a transistor (transistor ref. 1Tr1) provided on a single crystal semiconductor substrate (ref. 1 monocrystalline silicon semiconductor substrate). Additionally, Shibata teaches incorporation of such teaches a transistor (transistor ref. 1Tr1) provided on a single crystal semiconductor substrate to improve providing ease of incorporation of a driving integrated circuit and prevent the need for providing external driving integrated circuits (col. 2 lines 11-17). Rogers in the analogous art teaches a vacant spaced filled with a drying agent (desiccant ref. 31). Additionally, Rogers teaches incorporation of such a drying agent to improve drying and provide an improved organic EL apparatus that is highly resistant to water, oxygen and other environmental elements (col. 1 lines 66-67 and col. 2 lines 1 and 2). Kiwama et al. in the analogous art teaches barium oxide and silica gel drying agents (drying substance BaO col. 2 line 60 ref. 8). Additionally, Kiwama et al. teaches incorporation of such a BaO and silica gel to improve absorbing moisture and maintaining its solid state even after absorbing the moisture (abstract).

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use a bed and cover plate and packing material wherein an organic EL device is held wherein the vacant space is filled with an inert gas selected from the group consisting of helium, argon, krypton, xenon and nitrogen, in the active matrix oed array of Shi et al., since such a modification would improve light emission life and angle-of-view characteristics and prevent oxidation as taught by Eida.

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to have a transistor provided on a single crystal semiconductor substrate in the semiconductor substrate of Shi et al., since such a modification would improve providing ease of incorporation of a driving integrated circuit and prevent the need for providing external driving integrated circuits as taught by Shibata.

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use a drying agent in the space/gap in the active matrix oed of Shi, since such a modification would improve drying and provide an improved organic EL apparatus that is highly resistant to water, oxygen and other environmental elements as taught by Rogers.

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use BaO or silica gel in the active matrix oed of Shi, since such a modification would improve absorbing moisture and maintaining its solid state even after absorbing the moisture as taught by Kiwama et al.

Regarding claim 11, Shi et al. teaches an active matrix type organic EL display (title) device comprising: an insulating gate field effect transistor (ref. 30 gate oxide; transistor ref. 26 which is part of an OED ref. 39) provided on a semiconductor substrate (semiconductor substrate ref. 25) an EL layer comprising an organic material (organic layers ref. 41-43a) provided over the insulated gate field effect transistor a cover plate (separate glass substrate ref. 49), a binder layer (col. 8 line 10) and wherein the cover plate comprises a transparent material in a region of the cover plate overlapping with the pixel section (separate glass substrate ref. 49), but fails to teach a single crystal semiconductor substrate, a bed plate and cover plate formed of ceramics material, wherein the single crystal semiconductor substrate is held in a vacant space which is defined by the bed plate and the cover plate and the packing material wherein the vacant space is filled with an inert gas selected from the group consisting of helium, argon, krypton, xenon and nitrogen, and is filled with a drying agent selected from the group consisting of barium oxide and silica gel. Eida et al. in the analogous art teaches a bed plate (ceramic plate support substrate Fig. 1 ref. 2) and cover plate (transparent inorganic oxide substrate aluminum oxide ref. 4) and a binder layer (sealing means, bonding ref. 5) wherein an organic EL device is held (ref. 1 OED or OLED) wherein the vacant space is filled with an inert gas selected from the group consisting of helium, argon, krypton, xenon and nitrogen, (col. 21 lines 60-62). Additionally, Eida teaches incorporation of such a bed plate (ceramic plate support substrate Fig. 1 ref. 2) and cover plate (transparent inorganic oxide substrate ref. 4) and packing material (sealing means, bonding ref. 5) wherein an

Art Unit: 2879

organic EL device is held (r f. 1 OED or OLED) wherein the vacant space is filled with an inert gas (argon gas col. 21 lines 60-62) to improve light emission life and angle-ofview characteristics (abstract; col. 21 lines 64-67) and prevent oxidation (col. 21 line 63). Shibata et al. in the analogous art teaches a transistor (transistor ref. 1Tr1) provided on a single crystal semiconductor substrate (ref. 1 monocrystalline silicon semiconductor substrate). Additionally, Shibata teaches incorporation of such teaches a transistor (transistor ref. 1Tr1) provided on a single crystal semiconductor substrate to improve providing ease of incorporation of a driving integrated circuit and prevent the need for providing external driving integrated circuits (col. 2 lines 11-17). Rogers in the analogous art teaches a vacant spaced filled with a drying agent (desiccant ref. 31). Additionally, Rogers teaches incorporation of such a drying agent to improve drying and provide an improved organic EL apparatus that is highly resistant to water, oxygen and other environmental elements (col. 1 lines 66-67 and col. 2 lines 1 and 2). Kiwama et al. in the analogous art teaches barium oxide and silica gel drying agents (drying substance BaO col. 2 line 60 ref. 8). Additionally, Kiwama et al. teaches incorporation of such a BaO and silica gel to improve absorbing moisture and maintaining its solid state even after absorbing the moisture (abstract).

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use a bed and cover plate and packing material wherein an organic EL device is held wherein the vacant space is filled with an inert gas selected from the group consisting of helium, argon, krypton, xenon and nitrogen, in the active matrix oed array of Shi et al., since such a modification would

improve light emission life and angle-of-view characteristics and prevent oxidation as taught by Eida.

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to have a transistor provided on a single crystal semiconductor substrate in the semiconductor substrate of Shi et al., since such a modification would improve providing ease of incorporation of a driving integrated circuit and prevent the need for providing external driving integrated circuits as taught by Shibata.

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use a drying agent in the space/gap in the active matrix oed of Shi, since such a modification would improve drying and provide an improved organic EL apparatus that is highly resistant to water, oxygen and other environmental elements as taught by Rogers.

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use BaO or silica gel in the active matrix oed of Shi, since such a modification would improve absorbing moisture and maintaining its solid state even after absorbing the moisture as taught by Kiwama et al.

Claims 6 and 12 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shi et al. U.S. Patent 5,998,805 in view of Eida et al. U.S. Patent 5,909,081, Shibata et al. U.S. Patent 6,147,451, Rogers U.S. Patent 6,081,071, Kawami et al. U.S. Patent 5,882,761 and Rallison et al. U.S. Patent 6,097,543.

Art Unit: 2879

Regarding claim 6, Shi, Eida, Shibata, Rogers and Kawami et al. teach all the limitations of claim 6, but fail to teach use of an EL display device in a goggle type display device. Rallison in the analogous art teaches use of an EL display device in a goggle type display device (LED image generator for HMD ref. 2). Additionally, Rallison teaches incorporation of such a goggle type LED display to improve the combining of generated images with a view of the environment surround a user and transmit such combined visual information to the eye of the user (col. 1 lines 12-15).

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use a goggle type LED display in the active matrix OED of Shi, Eida, Shibata, Rogers and Kawami, since such a modification would improve improve the combining of generated images with a view of the environment surround a user and transmit such combined visual information to the eye of the user as taught by Rallison et al.

Regarding claim 12, Shi, Eida, Shibata, Rogers and Kawamit et al. teach all the limitations of claim 6, but fail to teach use of an EL display device in a goggle type display device. Rallison in the analogous art teaches use of an EL display device in a goggle type display device (LED image generator for HMD ref. 2). Additionally, Rallison teaches incorporation of such a goggle type LED display to improve the combining of generated images with a view of the environment surround a user and transmit such combined visual information to the eye of the user (col. 1 lines 12-15).

Consequently it would have been obvious to a person having ordinary skill in the art at the time the invention was made to use a goggle type LED display in the active

matrix OED of Shi, Eida, Shibata, Rogers and Kawami, since such a modification would improve improve the combining of generated images with a view of the environment surround a user and transmit such combined visual information to the eye of the user as taught by Rallison et al.

Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Taniguchi et al. U.S. Patent 5,239,228 discloses a Thin-Film Electroluminescence Device for Displaying Multiple Colors with Groove for Capturing Adhesive.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Glenn Zimmerman whose telephone number is (571) 272-2466. The examiner can normally be reached on M-W 8-5.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nimesh D Patel can be reached on (571) 272-2457. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Page 22

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Glenn Zimmerman

Vip Patel **Primary Examiner** AU 2879